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## Wireless Communication with Nanoplasmonic Data Carriers: <sup>2</sup> Macroscale Propagation of Nanophotonic Plasmon Polaritons <sup>3</sup> Probed by Near-Field Nanoimaging

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ABSTRACT: The ability to control the energy flow of light at the nanoscale is 10 fundamental to modern communication and big-data technologies, as well as quantum 11 information processing schemes. However, because photons are diffraction-limited, efforts 12 of confining them to dimensions of integrated electronics have so far proven elusive. A 13 promising way to facilitate nanoscale manipulation of light is through plasmon 14 polaritons-coupled excitations of photons and charge carriers. These tightly confined 15 hybrid waves can facilitate compression of optical functionalities to the nanoscale but suffer 16 from huge propagation losses that limit their use to mostly subwavelength scale 17 applications. With only weak evidence of macroscale plasmon polaritons, propagation has 18 recently been reported theoretically and indirectly, no experiments so far have directly 19 resolved long-range propagating optical plasmon polaritons in real space. Here, we launch 20 and detect nanoscale optical signals, for record distances in a wireless link based on novel 21 plasmonic nanotransceivers. We use a combination of scanning probe microscopies to 22 provide high resolution real space images of the optical near fields and investigate the long-23



range propagation of nanoscales optical signals. We design our nanotransceivers based on a high-performance nanoantenna, 24 *Plantenna*, hybridized with channel plasmon waveguides with a cross-section of 20 nm  $\times$  20 nm, and observe propagation for 25

distances up to 1000 times greater than the plasmon wavelength. We experimentally show that our approach hugely outperforms 26

both waveguide and wireless nanophotonic links. This successful alliance between Plantenna and channel plasmon waveguides 27

paves the way for new generations of optical interconnects and expedites long-range interaction between quantum emitters and 28

photomolecular devices. 29

**KEYWORDS:** Plasmonics, nanoantennas, channel waveguides, wireless, nanoimaging 30

he proposed scheme is designed to enable macroscale 31 32 communication between nanoscale devices utilizing 33 surface plasmon polaritons (SPPs). Hence, we use channel 34 waveguides that confine SPPs to their channel dimensions, 35 which can be as small as several nanometers.<sup>1-8</sup> However, as 36 dimensions decrease, SPPs exhibit increased losses that limit 37 their propagation in waveguides to distances of only few 38 micrometers. To address this fundamental limitation, we 39 convert channel SPPs to optical surface waves that propagate 40 for significantly larger distances on dielectric substrates. A high-41 efficiency nanoreceiver, designed to convert surface waves to 42 channel SPPs, is placed the remote edge of the system. Figure 43 1a illustrates the proposed communication nanosystem, which 44 (a) converts light to nanoscale SPPs, (b) propagates SPPs in 45 channel waveguide, (c) converts these SPPs to surface waves 46 and propagatea them for long distance, and (d) excites SPPs 47 from the surface waves at remote locations. As shown in the 48 right-hand side of Figure 1a, laser light illuminates the 49 Plantenna to launch SPPs at the waveguide. Second, Plantenna,

located at the other edge of the waveguide, converts these SPPs 50 to surface waves that propagate on the substrate. The surface 51 waves are reconverted to SPPs at a remote, Plantenna based 52 nanoreceiver. We use waveguides with a propagation loss of 53  $e^{-\alpha l}$ , where the absorption constant  $\alpha = (18 \ \mu m)^{-1}$  for a 54 channel width of 20 nm at a red wavelength of  $\lambda = 633$  nm and 55 *l* is the propagation length.

In contrast, absorption for wireless links occur only at the 57 antennas and are much lower than for a waveguide. For 58 conventional (e.g., dipole, bowtie) nanoantennas, the prop- 59 agation loss for wireless links behaves like  $(D/l)^2$ , where D is 60 the directivity.<sup>9</sup> Here, we show that Plantenna based wireless 61 links hugely outperform both waveguide and conventional 62 nanoantenna based alternatives. Figure 1b presents a 3D model 63 of the nanotransceiver, with zoom in to the Plantenna region 64

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**Figure 1.** Wireless communications with optical plasmon polaritons. (a) Illustration of the proposed nanoscale communication system. SPP launching Plantenna (right) converts free space light to propagating waveguides SPPs, which are coupled to surface waves by the "Surface Waves Launching Plantenna" for long-range propagation. A Plantenna based nanoreceiver (left) converts the surface waves to channel SPPS at remote distances. (b) 3D model of a Plantenna based plasmonic nanotransceiver. Zoom in to the Plantenna region is shown in the inset c, materials stack up used to fabricate the devices.

65 shown in the inset. The physical principle behind the Plantenna 66 invention is the enormous field enhancement and confinement 67 exhibited by resonant, optically illuminated adjacent metallic 68 nanoparticles. These properties, mainly originated from 69 coherent capacitive coupling between the particles, are 70 significantly better than those of isolated nanoparticles. The 71 Plantenna comprised of two metallic nanorods of length  $L_{\rm Arm}$ 72 separated by a nanoscopic gap (s = 10-35 nm), in a dipole 73 arrangement. An additional nanorod, termed director, is placed 74 at much closer proximity of only 7 nm ( $g \sim 7$  nm) to the 75 dipole. A detailed analysis on the Plantenna physics, which also 76 includes optimization for high efficiency excitation of channel 77 SPPs, was recently reported.<sup>5</sup> Figure 1c shows the material 78 stack up used in this work, comprised of 20 nm Au layer 79 deposited on a Si on insulator (SOI) wafer (500  $\mu$ m Si, 2  $\mu$ m 80 SiO<sub>2</sub>), for potential CMOS computability.

For nanofabrication, we use electron beam lithography 81 82 (EBL), ion beam sputtering (Au, 20 nm), and liftoff. After 83 liftoff, the resist is completely removed, allowing contact mode 84 near-field optical characterization. We fabricated devices 85 comprised of standalone nanotransceivers and complete 86 communication systems. Figure 2a shows a high-resolution 87 scanning electron microscopy (HR-SEM) image of a fabricated 88 nanotransceiver, recorded at beam current of 0.4 nA and low 89 accelerating voltage of 5 kV, for sub 1 nm imaging resolution; 90 corresponding 3D AFM topography is shown in Figure 2b. 91 Nanotransceivers with dimensions of  $L_{\rm Arm}$  = 220 nm,  $L_{\rm C}$  = 120 92 nm, s = 20 nm, g = 7 nm, and  $L_{WG} = 1.5 \ \mu m$  were fabricated 93 successfully and repeatedly. Figure 2c shows near-field KPFM 94 nanoimaging under illumination with a He–Ne laser ( $\lambda_0 = 633$ 95 nm), recorded at a set lift height of 30 nm using a high aspect 96 ratio uncoated Si AFM tip with a diameter of 2 nm. As 97 observed, the laser light is efficiently converted to propagating 98 plasmons at the waveguide channel by the Rx (right) Plantenna 99 and then recoupled to surface waves via the Tx (left) Plantenna. 100 Characterized by periodic peaks (purple) in the KPFM signal 101 imaged at the waveguide channel, SPPs with an effective

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**Figure 2.** Plantenna-based plasmonic nanotransceiver. (a) Highresolution SEM image of the fabricated nanotransceiver. (b) 3D AFM image of the fabricated nanotransceiver. (c) KPFM under optical illumination analysis of the nanotransceiver. KPFM signal scale bar:  $\pm 4.7$  V. (d) Numerically calculated optical near-field vector. (e) Numerically calculated optical near-field image showing  $\text{Re}(E_z) = |E_z|$  $\cos(\phi_z)$ . (f) Numerically calculated optical near-field showing  $\text{Re}(E_x)$ . (g) Numerically calculated optical near field showing  $\text{Re}(E_y)$ . Scale bar: 100 nm.

wavelength of 35–150 nm were measured. The experimental 102 results are reproduced by numerical calculation results, 103 presented at the optical frequency of 474 THz (633 nm). 104 The theoretical results are obtained using a high-frequency 105 structure simulator based on the finite element method 106 (FEM).<sup>3–5,10,11</sup> Numerical calculation results of the device 107 are shown in Figure 2d–g, with Figure 2d showing the local 108 near-field vector in 3D, and Figure 2e–g presenting the scalar 109 component of the electrical near-field magnitudes Re{ $|E_z|$ }, 110 Re{ $|E_x|$ }, and Re{ $|E_y|$ }, respectively.

The analysis of a nanoscale wireless communication system 112 that transmits and receives optical plasmon polaritons with a 113 cross section of 20 nm  $\times$  20 nm to distance of 12  $\mu$ m is shown 114 in Figure 3. The system is comprised of a plasmonic 115 f3 nanotransceiver (Figure 1b) and a nanoplasmonic receiver, 116 separated by a distance of 12  $\mu$ m. Figure 3a presents 3D AFM 117 topography mapping of the nanosystem, where the transceiver 118 is fabricated at the right-hand side and the receiver is located at 119 the left side. To image the near-field structure of long-range 120 plasmon polaritons transfer in real space, we use a combination 121 of KPFM and SNOM. KPFM enables near-field mapping of 122 plasmonic devices with a very high resolution. However, it has 123 limited efficiency in characterizing dielectric devices, mainly 124 since the work function of dielectric materials barely can be 125 modified by optical illumination.<sup>3,4,6,12</sup> Figure 3b shows KPFM 126 analysis of the nanosystem, illuminated by a He–Ne laser ( $\lambda = 127$ 633 m), linearly polarized in parallel to the dipole orientation 128 and focused to diameter of 700 nm. Channel SPPs are observed 129 at the nanotransceiver channel waveguide, propagate for 130



Figure 3. Characterization of the proposed wireless link, demonstrating efficient long-range propagation of tightly confined optical plasmon polaritons. (a) 3D AFM image of the fabricated wireless link system. (b) KPFM under optical illumination analysis of the wireless link system, showing SPPs at the transmission (right) and reception (left) sides; inset—zoom in to the respective waveguide channel. KPFM signal scale bar:  $\pm 4.7$  V. (c) SNOM analysis of the wireless link system, showing SPPs at the transmission (right) and reception (left) sides, as well as the coupling to surface waves that enable the long-range propagation. (d) Numerically calculated nearfield image, showing the complete optical wireless transfer link. Scale bar: 750 nm.

distance of  $L_{WG} = 1 \ \mu m$ , followed by strong "hot spot" at the Tx 131 Plantenna that converts them to surface waves. A zoom in to 132 the channel region is presented in the inset, clearly showing the 133 periodic structure of the excited SPPs. Remarkably, pronounced 134 SPP excitation is observed at the distanced receiver, which is 135 not illuminated by the laser. Highlighted in the left inset, the 136 channel SPPs at the receiver waveguide are excited by efficient 137 coupling of surface waves to SPP by the receiver Plantenna. 138 The surface waves on the SiO<sub>2</sub> surface are imaged in the near 139 field via SNOM, as shown in Figure 3c. Naturally, SNOM 140 provides lower resolution images compared to KPFM;<sup>3</sup> 141 however, its direct optical imaging mechanism enables mapping 142 of the surface photons that propagate on the dielectric medium, 143 unlike KPFM. Note that the SNOM image exhibits high 144 intensity at the physical locations of the transceiver and 145 receiver, originated by plasmon excitation. Hence, we state that 146 the combination of KPFM and SNOM provides a comple- 147 mentary, complete real-space nanoimaging approach for the 148 characterization of nanoscale wireless communication systems, 149 which facilitates high-resolution nanoimaging of both plasmons 150 and optical surface waves. Numerical calculation results of the 151 nanosystem, presenting the electric near-field magnitude |E|, are 152 shown in Figure 3d. Both channel SPPs as well as the surface 153 waves in the dielectric substrate are clearly captured, providing 154 additional confirmation to our approach. 155

To unambiguously demonstrate the excellent efficiency of 156 our Plantenna based nanosystem, we compare its performances 157 to direct channel waveguiding link<sup>6–8,13</sup> and to wireless link 158 based on dipole nanoantennas.<sup>14–17</sup> For the wireless link 159 configurations (Figure 4a–d) the distance between the 160 f4 transceiver and receiver is 10  $\mu$ m, and for the direct link 161 (e.g., Figure 4e–f) the waveguide length is 3  $\mu$ m, limited by 162 fabrication constraints. Figure 4a shows AFM image of our 163 proposed Plantenna based nanosystem, as the corresponding 164 KPFM mapping is shown in Figure 4b with a voltage scale bar 165 of ±4.7 V. Pronounced plasmon excitation is probed at the 166 receiver, evidenced by the modal structure of the field inside 167

![](_page_2_Figure_6.jpeg)

**Figure 4.** Comparison between nanophotonic links. (a) 3D AFM image of the Plantenna-based wireless link system. (b) KPFM under optical illumination analysis of the Plantenna-based wireless link system; KPFM signal scale bar:  $\pm 4.7$  V. (c) 3D AFM image of the dipole nanoantenna-based wireless link system. (d) KPFM under optical illumination analysis of the dipole nanoantenna-based wireless link system; KPFM signal scale bar:  $\pm 0.5$  V. (e) 3D AFM image of channel SPP waveguide with an identical cross section to the waveguides in a–d and 3  $\mu$ m length. (f) KPFM under optical illumination analysis of the channel SPP waveguide link; KPFM signal scale bar:  $\pm 4.7$  V; inset (b, d, f): zoom in to the respective waveguide channel. Scale bar: 1  $\mu$ m.

![](_page_3_Figure_2.jpeg)

**Figure 5.** Performance analysis for ultralong propagation distances. (a) Numerically calculated near field image, showing the complete Plantennabased wireless transfer link with distance of 35  $\mu$ m between the transmitting and receiving sides. (b) Performance comparison between Plantenna and dipole based wireless links for 35  $\mu$ m, showing a 30 dB better performance of the Plantenna configuration. (c) 3D AFM image of a threeelement Plantenna based transceiver phased array. Scale bar: 200 nm.

<sup>168</sup> the channel which is highlighted in the inset. Figure 4c shows <sup>169</sup> the AFM topography of a wireless link based on dipole <sup>170</sup> nanoantennas, which was recently proposed as an approach for <sup>171</sup> plasmonic energy transfer;<sup>18</sup> the corresponding KPFM image is <sup>172</sup> presented in Figure 4d with a voltage scale bar of  $\pm 0.5$  V.

We observe plasmon excitation at the transceiver; however, 173 174 significantly less noticeable intensity is measured at the receiver 175 waveguide (see inset) compared with the Plantenna based 176 architecture. Figure 4e shows a 3D AFM image of a Plantenna 177 integrated with a similar waveguide of 3  $\mu$ m length, implementing a direct nanoplasmonic link. Unlike the wireless 178 links, the waveguide exhibits much higher propagation loss 179 since it directly propagates tightly confined plasmons that 180 interacts with the metals in their entire guided route.<sup>18</sup> A 181 KPFM map of the direct link is shown in Figure 4f (scale bar 182  $\pm 4.7$  V), where the zoom in to the different channel regions is 183 presented in the insets. As seen in the right inset, channel SPPs 184 185 are excited by the Plantenna and propagate through the 186 waveguide. However, the huge propagation loss makes the waveguide SPPs decay significantly and being practically 187 188 unobservable after propagating for only 2.5  $\mu$ m, as seen in the left inset of Figure 4f. This reconfirms the critical, huge 189 190 losses exhibited in gap plasmon waveguides with nanoscale channels, which hamper their real life applicability. Figure 5a 191 shows the calculated electric near field for a Plantenna based 192 communication nanosystem with a 35  $\mu$ m distance between the 193 transmitter and receiver. Even for this high separation, plasmon 194 excitation is clearly observed in the receiving device. Dipole 195 196 nanoantenna is the most popular form of compact couplers to channel waveguide, enabling us to achieve 200 times higher 197 efficiency compared with the case of directly illuminating a base 198 waveguide.<sup>3,4,6,7,10,16</sup> Other types of couplers may use nano-199 200 focusing approaches<sup>15</sup> or more complex coupling devices like a 201 Yagi nanoantenna.<sup>19</sup> However, these devices are diffraction 202 limited and cause only marginal improvement compared with

the dipole coupler. A comparison between Plantenna and 203 dipole based systems with 35  $\mu$ m separation is shown in Figure 204 Sb, presenting the normalized near field along a line that 205 connects the transmitter and receiver passing through the 206 centers of both waveguides. The continuous black and blue 207 charts represent the calculated results of a Plantenna and dipole 208 wireless systems, respectively, as the discrete red and green 209 squared dots are the corresponding experimental results. High 210 field values are observed in both Tx and Rx ends, attributed to 211 plasmon enhancement by the nanoantennas. As expected, the 212 field is attenuated linearly when propagates through the SiO<sub>2</sub> 213 substrate. 214

A quantitative comparison between Plantenna and dipole 215 systems is performed by comparing the SPP magnitude at both 216 receiver waveguides, which serve as input for remote nano- 217 plasmonic circuits<sup>4,12,20</sup> or can be probed by photoelectric 218 detectors. Since both systems are excited with identical sources 219 and use similar plasmon waveguides, this approach is equivalent 220 to calculating the ratio between the wave power of the SPP at 221 the receiver waveguide and the laser source. As seen in Figure 222 5b, the Plantenna based nanosystem outperforms the dipole 223 configuration by more than 30 dB. Note that from nano- 224 fabrication considerations we use Plantenna with identical 225 dimensions through all of the experiments herein. However, the 226 additional significant efficiency improvement can be achieved 227 using a structural optimization of the different Plantennas as we 228 recently reported.<sup>5</sup> The Plantenna nanosystem can be used to 229 wirelessly transfer optical nanoplasmonic information for 230 macroscale distances using a phased array<sup>21-24</sup> configuration 231 as shown in Figure 5c. By fabricating an array of identical 232 transceivers spaced by  $\lambda_0/2$  ( $\lambda_0$  is the free space wavelength), 233 the emitted surface waves coupled from all of the transceivers 234 can be coherently combined on the surface. Based on the well- 235 known Friis principle,<sup>18,25,26</sup> the phased array architecture 236 enables propagation distances which are linearly scalable with 237

238 the number of transceivers, paving the way toward efficient 239 wireless nanoplasmonic data and energy transfer for millimeter 240 distances and beyond.

In conclusion, we designed, fabricated, and experimentally 241 242 characterized a novel high-efficiency nanosystem, capable to 243 wirelessly transfer deeply confined optical plasmon polaritons 244 for chip-scale distances. Our system is architectured for the 245 efficient conversion of nanoscopic SPPs to propagating surface 246 waves and to re-excite SPPs from these surface waves at significantly remote distances. We demonstrate the trans-247 248 mission of optical SPPs in channel waveguides with a cross 249 section of only 20 nm  $\times$  20 nm, for distances which are 3 250 orders of magnitude larger than the plasmon wavelength. On 251 the basis of the Plantenna, a new generation of highperformance nanoantennas with no RF equivalents, our 252 253 nanosystem hugely outperforms both direct and wireless links 254 based on dipole nanoantennas by more than 30 dB. For the first 255 time, we use a unique combination of scanning probe 256 microscopies to create complete real-space near-field mapping 257 of a long-range nanoplasmonic wireless link at a high spatial resolution. This nanoimaging amalgamation provides valuable 258 259 synergy needed for mapping both nanoscopic plasmon 260 polaritons as well as macroscopically propagating surface 261 waves. In the quest for reconciling the dimensional mismatch 262 between diffraction-limited photonics and integrated elec-263 tronics, our results enable new horizons for high integration 264 densities of optical functionalities and interconnects. By using 265 phased array configuration and utilizing degrees of freedom in 266 polarization, frequency and code domains, inter- and intra-chip 267 communications based on ultrafast nanoscale light waves as 268 information carriers can now achieve record performances in 269 terms of speed distance and size. The presented approach of 270 hybridizing Plantenna and channel plasmon waveguides as 271 nanotransceivers is immediately applicable for exploring long-272 range interaction between single and multiple quantum 273 emitters, while our nanoimaging methodology enables 274 enhanced understanding of exciting near-field phenomena at 275 the nanoscale.

Methods. AFM and KPFM Measurements. All measure-276 277 ments were performed at room temperature and free ambient conditions (no vacuum), using a Dimension Icon AFM system 278 with a NanoScope V controller (Bruker). For both AFM and 279 280 KPFM measurements, we used NanoWorld probes SSS-NCH (SuperSharpSilicon, Noncontact/Tapping mode, High reso-281 282 nance frequency), with a typical diameter of 2 nm, resonance 283 frequency of 320 kHz, and spring constant of 42 N/m. Typically, voltages of 2 V, AC capacitance frequencies of 880 284 285 MHz, lift heights of 30-50 nm, and line rates of 0.1 kHz were employed. To map the CPD of the sample, we apply both AC 286 voltage (VAC) and DC voltage (VDC) to the AFM tip. VAC 287 generates oscillating electrical forces between the AFM tip and 288 289 sample surface, and VDC nullifies the oscillating electrical 290 forces that originated from CPD between tip and sample surface. 291

*Optical Near-Field Measurements.* The optical characterization of the plasmonic structures was performed by a MultiView 2000 scanning probe microscope/NSOM system (Nanonics Imaging Ltd.). The SPM head was placed on the stage of an Olympus dual microscope while remaining the optical axis free from above and below. Such a configuration allowed us to bring the cantilevered NSOM tip to the desired position on the sample under an upper objective of 50×. The some sample was illuminated with a Liconix diode laser of 785 laser

CW light from the bottom and focused on a sample with a  $50 \times 301$ objective. We used the bottom piezo scanner of the scanning 302 head to place the desired structures of the sample very 303 accurately relatively to the incoming light of the laser from 304 below. The scan was performed with upper piezo scanner 305 allowing moving only the NSOM tip while the sample remains 306 still. The collection of near field light distribution on the surface 307 was performed in tapping mode with a 200 nm aperture 308 NSOM tips based tuning fork produced by Super Tips 309 (Nanonics Imaging Ltd.). The signal was transmitted through 310 a multimode optical fiber onto an APD. The AFM and NSOM 311 images were collected simultaneously during the scan, allowing 312 to monitor the topography of the desired structure and to 313 correlate it with the near-field optical signal that comes from 314 any particular feature. 315

Numerical Simulations. The numerical results are obtained 316 by using the software package ANSYS HFSS V15, the industry- 317 standard simulation tool for 3D full-wave electromagnetic field 318 simulation. HFSS solves Maxwell's equations via the finite 319 element method (FEM) using an adaptive mesh refinement 320 process for tailored accuracy requirements. The field's solutions 321 are calculated with the metallic (Ag) plasmonic structures being 322 deposited on a homogeneous SiO<sub>2</sub> substrate. The nanoantenna 323 is illuminated by optical sources at 474 THz (wavelength of 324 633 nm), which are modeled as focused Gaussian beams with 1 325  $\mu$ m characteristic diameter. The electric field is polarized in 326 parallel with the dipole direction, as the wave vector K is 327 perpendicular. A selectively dense meshing is assigned in the 328 metallic and waveguiding regions, with a maximum cell size of 1 329 nm and 750 000 FEM tetrahedral cells. To provide maximum 330 accuracy, the model is terminated as following: the interface 331 with free space is bounded by perfectly matched layer (PML) 332 absorbing boundary conditions (ABC), while the metallic and 333 SiO<sub>2</sub> termination are done via layered impedance (LI) ABC. 334 The minimum number of adaptive meshing iterations was set 335 to 12, with a convergence condition of 1% maximum energy 336 variance between adjacent iterations. 337

*Fabrication.* SiO<sub>2</sub>/Si sample was spin-coated with poly- 338 (methyl methacrylate) (PMMA 950 A2) electron-beam resist 339 providing thickness of 100 nm. The samples coated with 340 PMMA were subsequently baked for 120 s on a hot plate at 341 180C. The desired pattern was exposed in the PMMA layer 342 using a CRESTEC CABLE-9000C high-resolution electron- 343 beam lithography system using different doses to control line 344 and gap width. Then the samples were developed for 90 s using 345 methyl isobutyl ketone (MIBK) and rinsed with IPA. The 346 samples were subsequently exposed to Ar plasma to etch 10 nm 347 in order to remove leftovers from the pattern, sputtered using 348 BESTEC 2" DC magnetron to deposit 2 nm Cr and 18 nm Au, 349 and then immersed in 180 Khz ultrasonic bath with NMP for 3 350 h for resist liftoff.

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M.C. carried out the theoretical design and analysis, designed 358 the studies, performed the experiments, and wrote the 359 manuscript. Z.Z. and R.S. participated in writing the manuscript 360 and designing the study. 361

#### 362 Notes

363 The authors declare no competing financial interest.

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